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1	Supplementary Information			
2 3 4 5 6	Durable Superhydrophilic/phobic Surfaces Based on Green Patina with Corrosion Resistance			
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Nickel s	strike	Copper plating	
HCl	125 g/L	CuSO ₄ ·5H ₂ O	70 g/L
NiSO ₄ ·6H ₂ O	240 g/L	NaCl	0.6 g/L
current	0.1 A/cm ²	H_2SO_4	50 g/L
time	30 sec.	PEG	0.02 g/L
		current	0.3 A/cm ²
		time	5 min [.]

- **Table S1.** The composition of the plating bath and process parameters for electroplating copper
 film on stainless steel mesh.
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- 5 Fig. S1 FE-SEM images of the fabricated mesh covered with (a) brochantite structure, (b) copper
- 6 thiolate structure. Scale bars indicate 50 $\mu m.$
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Fig. S2 FE-SEM images and XRD patterns of CuO structure. (a) CuO film grown on the copper plate by chemical oxidation. Scale bar indicates 5 μ m. (b) XRD Patterns of CuO and copper substrate. The solid lines indicate the XRD pattern of powder diffraction file for CuO and the \star represents peaks from the copper plate.